Unlike other flowables, this product can be used for Class I, II, III, IV, and V restorations. The full list of indications are:

- Class I, II, III, IV, and V cavities
- Fissure sealant
- Sealing hypersensitive areas
- Repair of direct and indirect aesthetic restorations
- Blocking out undercuts
- Liner or base
- Temporary crown and bridge
- Defect margins when margins are in enamel

Advanced filler technology results in exceptional physical properties* that allow you to use this flowable in more ways, with beautiful results:

- High flexural strength (167 MPa) – can use all the way to the occlusal surface and incisal edge
- Superior gloss retention – maintains gloss for beautiful restorations
- Excellent wear resistance – resists staining and wear for excellent durability

*Data on file.
Use G-ænial Universal Flo in combination with G-ænial Bond for the best possible results (both products are compatible with all other standard bonding and composite restorative products). G-ænial Bond was designed specifically to provide the option of selective etching:

• A self-etch approach on dentin (simple, and reduced risk of post-op sensitivity)
• An etch-and-rinse approach on enamel (higher bond strength on uncut enamel)

In self-etch mode:

1. Application
2. Etch, recommend 35 - 40% phosphoric acid
3. Waiting
4. Dry - MAX
5. Light cure
6. Application
7. Irradiation Time – G-ænial Bond
<table>
<thead>
<tr>
<th>Light curing unit</th>
<th>Distance from light guide tip</th>
</tr>
</thead>
<tbody>
<tr>
<td>Halogen/LED</td>
<td>10 sec.</td>
</tr>
<tr>
<td>Silverlight</td>
<td>5 sec.</td>
</tr>
<tr>
<td>Plasma arc</td>
<td>3 sec.</td>
</tr>
</tbody>
</table>
8. Apply G-ænial Universal Flo in the desired shade

In selective etch mode:

1. Etch, recommend 35 - 40% phosphoric acid
2. Rinse
3. Gently dry
4. Application
5. Irradiation Time and Effective Depth of Cure – G-ænial Universal Flo
   | Irradiation time | 9 sec. (Plasma arc) (2000mW/cm²)
   | 10 sec. (Silverlight) (1200mW/cm²)
   | 20 sec. (Halogen/LED) (700 mW/cm²)
8. Apply G-ænial Universal Flo in the desired shade

Visit www.g-aenial.com for more techniques and tips on using G-ænial Universal Flo

Scan with your smartphone for more information!
This flowable is an excellent choice as a cavity liner or base, with high strength and radiopacity. Its full list of indications include:

- Cavity liner or base
- Blocking out undercuts
- Repair of direct and indirect aesthetic restorations
- Temporary crown and bridge
- Defect margins when margins are in enamel
- Sealing
- Tunnel restorations
- Direct restorative for small Class I, II, III, IV and V cavities
Use G-ænial Flo in combination with G-ænial Bond for the best possible results (both products are compatible with all other standard bonding and composite restorative products). G-ænial Bond was designed specifically for selective etching:

- A self-etch approach on dentin (simple, and reduced risk of post-op sensitivity)
- An etch-and-rinse approach on enamel (higher bond strength on uncut enamel)

### In self-etch mode:

1. **Application**
2. **Waiting**
3. **Dry - MAX**
4. **Light cure**
5. **Apply G-ænial Flo in the desired shade**

### In selective etch mode:

1. **Etch, recommend 35 - 40% phosphoric acid**
2. **Rinse**
3. **Gently dry**
4. **Application**
5. **Waiting**
6. **Dry - MAX**
7. **Light cure**
8. **Apply G-ænial Flo in the desired shade**

#### Irradiation Time and Effective Depth of Cure – G-ænial Flo

<table>
<thead>
<tr>
<th>Shade</th>
<th>Irradiation time</th>
<th>Effective Depth of Cure</th>
</tr>
</thead>
<tbody>
<tr>
<td>A1, A2, A3, A3.5, A4, CV</td>
<td>9 sec. (Plasma arc) (2000mW/cm)</td>
<td>1.5 mm</td>
</tr>
<tr>
<td>AO2, AO3</td>
<td>10 sec. (Silverlight) (1200mW/cm) 20 sec. (Halogen/LED) (700 mW/cm)</td>
<td>1.0 mm</td>
</tr>
</tbody>
</table>